

EAST Search History**EAST Search History (Interference)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S92	6	((EUV or UV or VUV or DUV or X\$2ray or ultraviolet) near22 (laser or ablat\$4 or irradiat\$4 or illuminat\$4 or expos\$4) near22 (resist or photoresist) near20 (pattern) near29 strip\$4 near29 (remov\$5)) and (((resist or photoresist) near12 (residu\$3 or remain\$4)) near26 (UV or EUV or DUV or X\$3ray or VUV or ultraviolet) near22 (irradiat\$4 or illuminat\$4 or imping\$4 or expos\$4) near29 develop\$4)	USPAT; UPAD	OR	ON	2010/06/10 13:34
S93	2	((EUV or UV or VUV or DUV or X\$2ray or ultraviolet or light) near22 (laser or ablat\$4 or irradiat\$4 or illuminat\$4 or expos\$4) near22 (resist or photoresist) near20 (develop\$4 or pattern) near29 etch\$4 near26 (metal\$4 or conductive)) and ((resist or photoresist or photosensitive) near14 pattern near12 strip\$4 near29 (remov\$5)) and (((resist or photoresist) near12 (residu\$3 or remain\$4) near24 (light or	USPAT; UPAD	OR	ON	2010/06/10 13:51

		UV or EUV or DUV or X-ray or VUV or ultraviolet) near (irradiation or illumination or impinging or exposure) same development and (metal near etch near pattern)				
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6/ 10/ 10 1:53:40 PM

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